

jc997 U.S. PTO  
10/005347  
12/07/01

78

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application



APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10005347	12/07/2001	524		1712	

\*\*APPLICANTS: Kozawa Miwa; Watanabe Keiji; Yano Ei;

\*\*CONTINUING DATA VERIFIED: *y*  
THIS APPLICATION IS A DIV OF 09/553,479 04/20/2000 PAT 6,342,562

*K11*

\*\* FOREIGN APPLICATIONS VERIFIED: *y*

JAPAN 11-116517 04/23/1999

JAPAN 2001-03/23 2000

*161*

PG-PUB	<input type="checkbox"/> DO NOT PUBLISH	<input type="checkbox"/> RESCIND	
Foreign priority claimed 35 USC 119 conditions met Verified and Acknowledged Examiners's initials		<input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <i>[initials]</i>	ATTORNEY DOCKET NO 100021-00065
TITLE : Silicon-containing polymer, process for its production, resist composition employing it, pattern-forming method and electronic device fabrication method			
U.S. DEPT. OF COMM./PAT & TM-PTO-436L (Rev. 12-94)			

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Kuo-Ling Ping 5/14/02 Assistant Examiner	
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		<i>1</i>	<i>3</i>
TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
		Application Examiner	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.			

FILED WITH:  DISK (CRF)  CD-ROM  
(Attached in pocket on right inside flap)